Quantum spin Hall effect in monolayer and bilayer TaIrTe₄

Peng-Jie Guo, Xiao-Qin Lu[®], Wei Ji[®], Kai Liu[®],^{*} and Zhong-Yi Lu[†]

Department of Physics and Beijing Key Laboratory of Opto-electronic Functional Materials & Micro-nano Devices, Renmin University of China, Beijing 100872, China

(Received 5 November 2019; revised 22 May 2020; accepted 25 June 2020; published 8 July 2020)

Generally, stacking two quantum spin Hall insulators gives rise to a trivial insulator. Here, based on firstprinciples electronic structure calculations, we confirm that monolayer TaIrTe₄ is a quantum spin Hall insulator and remarkably find that bilayer TaIrTe₄ is still a quantum spin Hall insulator. Theoretical analysis indicates that the covalentlike interlayer interaction in combination with the small band gap at the time-reversal invariant Γ point results in new band inversion in bilayer TaIrTe₄, namely, the emergence of quantum spin Hall phase. Meanwhile, a topological phase transition can be observed by increasing the interlayer distance in bilayer TaIrTe₄. Considering that bulk TaIrTe₄ is a type-II Weyl semimetal, layered TaIrTe₄ thus provides an ideal platform to realize different topological phases at different dimensions.

DOI: 10.1103/PhysRevB.102.041109

Introduction. Topological properties of real materials have attracted much attention both experimentally and theoretically in recent years. A quantum spin Hall (QSH) insulator, namely, a two-dimensional topological insulator, has a band gap in the bulk and the topologically protected metallic states at the edge [1,2]. Theoretically, the stacking of two QSH insulators together gives rise to a trivial insulator. Nevertheless, in real materials, a non-negligible, even strong interlayer interaction may exist for two stacked QSH insulators, which may lead to broadening of valence and conduction bands. As a result, one may ask: is it possible that stacking two quantum spin Hall insulators still gives rise to a QSH insulator in real materials? If so, this will provide a new platform for studying the QSH effect with more adjustable freedom. Due to the interlayer interaction, stacking two bilayer Bi(111) films still results in a QSH insulator [3-6]. So a natural idea is whether or not a weak van der Waals (vdW) interaction can lead to a similar result.

The interlayer interactions in vdW materials have given rise to many interesting physical phenomena and attracted intensive attention recently, for example, the layer-dependent ferromagnetism in CrI₃ [7]. Among various layered topological materials, tellurides have been intensively studied. Layered WTe₂ is a type-II Weyl semimetal in bulk form [8] while its monolayer is a QSH insulator with a direct band gap [9]. Bulk TaIrTe₄, sharing the same nonsymmorphic space group symmetry as WTe₂, was firstly proposed to be a type-II Weyl semimetal with the minimum four Weyl points under timereversal symmetry constraint [10-13]. A later joint theory and experiment study suggested that bulk TaIrTe₄ has 12 Weyl points and a pair of node lines protected by a mirror symmetry [14]. Meanwhile, two studies indicated that monolayer TaIrTe₄ is a QSH insulator [15,16]. Considering that tellurides show abundant layer-dependent electronic structures [17,18],

it is interesting to investigate the topological properties of TaIrTe₄ at the two-dimensional (2D) limit.

In this Rapid Communication, based on first-principles electronic structure calculations, we confirm that monolayer TaIrTe₄ is a quantum spin Hall insulator [15]. More interestingly, in contrast to the general perception that stacking two quantum spin Hall insulators would give rise to a trivial insulator, we exceptionally find that bilayer TaIrTe₄ is still a quantum spin Hall insulator. We have further explored the underlying physical mechanism theoretically.

Method. The electronic structures of ultrathin film TaIrTe₄ were studied with the projector augmented wave method [19,20] as implemented in the VASP package [21–23]. Perdew-Burke-Ernzerhof-type exchange-correlation The functional at the generalized gradient approximation level was adopted to describe the interaction between ionic core and valence electrons [24]. The kinetic energy cutoff of the plane-wave basis was set to 400 eV. The Gaussian smearing method with a width of 0.05 eV was utilized for the Fermi surface broadening. For the structural relaxation of bulk TaIrTe₄, the optB86b-vdW functional [25] was adopted to account for the interlayer interactions and an $18 \times 6 \times 6$ k-point mesh was used for the Brillouin zone (BZ) sampling. Both cell parameters and internal atomic positions were fully relaxed until the forces on all atoms were smaller than 0.01 eV/Å. The calculated lattice parameters of bulk TaIrTe₄ are in good agreement with the experimental values [26]. For the monolayer and bilayer calculations, the in-plane lattice constants were fixed to the relaxed bulk values, while the internal atomic positions were fully relaxed with an $18 \times 6 \times 1$ k-point mesh for the surface BZ sampling. A 20 Å vacuum layer was used to avoid the residual interaction between adjacent layers. The topological invariants and the edge states of monolayer and bilayer TaIrTe₄ were studied at the equilibrium structures by using the WannierTools package [27].

Results. Similar to type-II Weyl semimetal WTe_2 , bulk TaIrTe₄ has a noncentrosymmetric crystal structure, adopting

^{*}kliu@ruc.edu.cn

[†]zlu@ruc.edu.cn



FIG. 1. (a) Crystal structure of bulk TaIrTe₄. The red, green, and blue balls denote Ta, Ir, and Te atoms, respectively. The dashed rectangle highlights the layered structure. (b) Top view of monolayer TaIrTe₄, where Te atoms are hidden for clarity. Several typical interatomic distances are labeled. The dashed lines with labels "left" and "right" denote two different terminations of thin-layer TaIrTe₄, respectively. (c) Surface Brillouin zone (BZ) of monolayer TaIrTe₄. The red dots represent the high-symmetry k points.

a layered 1T' structure and *AB* stacking, as shown in Fig. 1(a). Due to the structural distortion along the *b* axis, Ta and Ir atoms form zigzag chains along the *a* axis [Fig. 1(b)]. The space group symmetry of bulk TaIrTe₄ is *Pmn2*₁, and the corresponding four point-group symmetric operations are identity *E*, mirror reflection M_x , screw operation $\{C_{2z}|(1/2, 0, 1/2)\}$, and glide reflection $\{M_y|(1/2, 0, 1/2)\}$, respectively.

Due to its layered structure, one would like to know whether or not TaIrTe₄ can be exfoliated as many other 2D materials. We calculated the energy of TaIrTe₄ as a function of the interlayer distance. As shown in Fig. 2, the cleavage energy of TaIrTe₄ is 0.43 J/m^2 , which is slightly larger than that of graphite (0.36 J/m^2) [28]. This indicates that an atomically thin film of TaIrTe₄ is likely obtained by mechanical exfoliation as graphene. In fact, an atomically thin film of TaIrTe₄ has been obtained by mechanical exfoliation [29].



FIG. 2. Evolution of the total energy of bulk TaIrTe₄ with interlayer distance d. Here d_0 denotes the equilibrium interlayer distance.

To study the possible topological property of bilayer TaIrTe₄, we need to first clarify the electronic structure of monolayer TaIrTe₄. In comparison with bulk TaIrTe₄, the space group of monolayer TaIrTe₄ changes to $P12_1/m1$ with additional inversion symmetry, but losing nonsymmorphic symmetry operation of the fractional translation along the *c* axis. The corresponding surface Brillouin zone (SBZ) and the high-symmetry *k* points are shown in Fig. 1(c). From the calculated density of states (DOS) [Fig. 3(a)], we can see that the states around the Fermi level are mainly contributed by Te *p* orbitals and Ta *d* orbitals, while Ir *d* orbitals have relatively small contributions. The common peaks among these states indicate strong *p*-*d* hybridization in monolayer TaIrTe₄.

The band structure of monolayer TaIrTe₄ along the highsymmetry paths of SBZ calculated without spin-orbit coupling (SOC) and with SOC are shown in Figs. 3(b) and 3(c), respectively. Without SOC, monolayer TaIrTe₄ is a Dirac semimetal, which has a band crossing along the S-Y path and a band inversion around the Y point [Fig. 3(b)]. Moreover, the bands around the Fermi level have small dispersion along the Γ -Y path, which is vertical to the atomic chain direction (a axis) in real space [Fig. 1(b)]. We have also examined the band structure by using the hybrid functional with the HSE06 version [30], which gives similar results. When including SOC, notable changes take place in the band structure. Monolayer TaIrTe₄ transforms to an insulator with a band gap of 32 meV. Meanwhile we also calculated the topological invariant Z_2 by using the Wilson loops method [31] and obtained the topological invariant Z_2 as 1. This demonstrates that monolayer TaIrTe₄ is a quantum spin Hall insulator [15,16], similar to monolayer WTe₂ [9].

According to the bulk-boundary correspondence, the nontrivial topological property of bulk accompanies the nontrivial edge or surface states at its boundaries. The edge states of monolayer TaIrTe₄ were calculated in the open boundary condition. Both the left and right terminated edges of monolayer TaIrTe₄ along the *b* axis are made up of Ta, Ir, and Te atoms [Figs. 1(a) and 1(b)]. As a result, the edge states at the left and



FIG. 3. Electronic structure of monolayer $TaIrTe_4$: (a) density of states; band structures calculated (b) without and (c) with spin-orbit coupling.

right terminations along the *b* axis are very similar [Figs. 4(a) and 4(b)] even though the two terminations are in difference with a fractional translation [Fig. 1(b)]. Meanwhile, the Dirac cone located at the $\overline{\Gamma}$ point is very close to the Fermi level.

In comparison with monolayer TaIrTe₄, the space inversion symmetry is absent in bilayer TaIrTe₄. Bilayer TaIrTe₄ has the P1m1 symmorphic space group symmetry. The corresponding point-group symmetry operations contain invariant *E* and mirror reflection M_x . Figure 5 shows the calculated band structure of bilayer TaIrTe₄. The bilayer appears to be a Weyl semimetal without including SOC, as shown in Fig. 5(a), in which there is a band crossing along the Γ -*X* path as well as band inversion around the Γ point of the SBZ. With the inclusion of SOC, the spin degeneracy is lifted due to breaking space inversion symmetry. The antisymmetric SOC is so strong that it results in a large band splitting [Fig. 5(b)]. Meanwhile, the band crossing along the Γ -*X* path opens an 8-meV gap [inset in Fig. 5(b)]. Remarkably, the calculated topological invariant Z_2 is equal to 1, indicating that bilayer TaIrTe₄ is still a QSH



FIG. 4. Spectral function of monolayer $TaIrTe_4$ with a semiinfinite termination edge. The corresponding edge states are highlighted by red arrows. The white-black color scale represents the spectral density with the unit of states per eV.

insulator. We have also examined the band structure by using the SCAN functional [32], which gives similar results.

We further calculated the edge states of bilayer TaIrTe₄ with the open boundary condition. The calculated helical edge states of left and right terminations along the *b* axis are shown in Figs. 6(a) and 6(b), respectively. On this occasion, the two edge states show a difference. The Dirac cone overlaps with the bulk states at the left edge, but not at the right edge. In addition, the Dirac cone of helical edge states for bilayer TaIrTe₄ is located at the \overline{X} point, instead of the $\overline{\Gamma}$ point in monolayer TaIrTe₄ (Fig. 4).

Although stacking of two QSH insulators is usually considered to give rise to a trivial insulator, once there appear new band inversions, this may, again, make the bilayer nontrival. The calculations show that there are two bands near the Fermi level inverting once around the Γ point [Fig. 5(b)], this makes bilayer TaIrTe₄ still a QSH insulator. The underlying reason is as follows. In many layered materials, strong interlayer wave-function overlap of p orbitals does occur, known as covalentlike quasibonding (CLQB), which is a result of balanced dispersion attraction and, mostly, Pauli repulsion. The formation of CLQB induces broadening of valence and conduction bands and thus shows layer-dependent band gaps and other electronic structure related properties [18,33–35]. Previously, both elemental layers and compounds of tellurium were found to possess such covalentlike interlayer interaction [17,18]. For bilayer TaIrTe₄, the left inset of Fig. 7(a) depicts



FIG. 5. Band structures of bilayer TaIrTe₄ calculated (a) without and (b) with SOC. Inset shows the enlarged band structure around the Γ point.

a plot of interlayer differential charge densities (DCD) at the equilibrium interlayer distance d_0 , which explicitly shows charge accumulation (covalent characteristic) at the interlayer region. As shown in Fig. 3, the band gap of monolayer TaIrTe₄ is small around the Γ point. Thus the largely broadened valence and conduction bands of bilayer TaIrTe₄ give rise to a band inversion over the small band gap around the Γ point [Fig. 5(b)]. In contrast, monolayer WTe₂ is a QSH insulator [9] as well as with the covalentlike interlayer bonding, but it possesses large band gaps at the time-reversal invariant points. As a result, bilayer WTe₂ is a trivial insulator, as verified by the calculations. Thus the QSH phase is a distinct property of bilayer TaIrTe₄.

The interlayer wave-function overlap should gradually weaken as the interlayer distance d increases. Therefore the bilayer will undergo a topological phase transition with the increasing interlayer distance. This analysis is confirmed by our calculation that topological invariant Z_2 of the bilayer goes from 1 to 0 in between $d - d_0 = 0.5$ and 1 Å (Fig. 7), indicating a topological nontrivial to trivial transition. While the interlayer charge sharing is clearly shown in DCD plots at distances near d_0 , no appreciable charge sharing is observable at an interlayer distance $d - d_0 = 2$ Å [Fig. 7(b)], suggesting the CLQB is eliminated.

Discussion. As analyzed above, the covalentlike interlayer interaction and the small band gap at the time-reversal invariant point are key factors for the emergence of the QSH phase in bilayer TaIrTe₄. Considering that the covalentlike interlayer



FIG. 6. Spectral function of bilayer TaIrTe₄ left (a) and right (b) terminations. Refer to Fig. 1(b) for the definition of left and right terminations. The corresponding edge states are highlighted by red arrows. The white-black color scale represents the spectral density with the unit of states per eV.

interaction exists quite popularly in real layered materials, our study suggests that other bilayers or vdW heterostructrues may also realize interesting topological phases, for example, Dirac, Weyl, and node-line semimetals, besides QSH insulators.



FIG. 7. Topological invariant Z_2 with increasing interlayer distance for bilayer TaIrTe₄. Differential charge densities for (a) equilibrium structure ($d = d_0$) and (b) enlarged interlayer distance ($d = d_0 + 2$ Å), respectively. Here only positive differential charge densities are illustrated.

A very recent transport experiment found that bulk TaIrTe₄ becomes superconducting under pressure [36]. Similarly, the superconductivity in bulk WTe₂ [37,38] can be induced by pressure, while the transition from 2D topological insulator to superconductor is driven in monolayer WTe₂ via the application of gate voltage [39]. Nontrivial topological superconductivity in monolayer and bilayer TaIrTe₄ may also be induced by gate voltage or stress. Furthermore, due to the broken inversion symmetry, Ising superconductivity [40] may be realized in bilayer TaIrTe₄.

Summary. Based on first-principles electronic structure calculations, we confirm that monolayer TaIrTe₄ is a QSH insulator. The Dirac cone of its robust helical edge states located at the $\overline{\Gamma}$ point is very close to the Fermi level. Remarkably, due to the covalentlike interlayer interaction and the small band gap at the time-reversal invariant Γ point, bilayer TaIrTe₄ is still

- [1] M. Z. Hasan and C. L. Kane, Rev. Mod. Phys. 82, 3045 (2010).
- [2] X. L. Qi and S. C. Zhang, Rev. Mod. Phys. 83, 1057 (2011).
- [3] Z. Liu, C. X. Liu, Y. S. Wu, W. H. Duan, F. Liu, and J. Wu, Phys. Rev. Lett. 107, 136805 (2011).
- [4] D. C. Wang, L. Chen, H. M. Liu, and X. L. Wang, J. Phys. Soc. Jpn. 82, 094712 (2013).
- [5] L. Miao, M. Y. Yao, W. M. Ming, F. F. Zhu, C. Q. Han, Z. F. Wang, D. D. Guan, C. L. Gao, C. H. Liu, F. Liu, D. Qian, and J. F. Jia, Phys. Rev. B **91**, 205414 (2015).
- [6] L. Peng, J. J. Xian, P. Z. Tang, A. Rubio, S. C. Zhang, W. H. Zhang, and Y. S. Fu, Phys. Rev. B 98, 245108 (2018).
- [7] B. Huang, G. Clark, N. M. Efrén, D. R. Klein, R. Cheng, K. L. Seyler, D. Zhong, E. Schmidgall, M. A. McGuire, H. C. David, W. Yao, D. Xiao, J. H. Pablo, and X. D. Xu, Nature (London) 546, 270 (2017).
- [8] A. A. Soluyanov, D. Gresch, Z. J. Wang, Q. S. Wu, M. Troyer, X. Dai, and B. A. Bernevig, Nature (London) 527, 495 (2015).
- [9] X. F. Qian, J. W. Liu, L. Fu, and J. Li, Science **346**, 1344 (2014).
- [10] K. Koepernik, D. Kasinathan, D. V. Efremov, S. Khim, S. Borisenko, B. Büchner, and J. van den Brink, Phys. Rev. B 93, 201101(R) (2016).
- [11] S. Khim, K. Koepernik, D. V. Efremov, J. Klotz, T. Förster, J. Wosnitza, M. I. Sturza, S. Wurmehl, C. Hess, J. van den Brink, and B. Büchner, Phys. Rev. B 94, 165145 (2016).
- [12] I. Belopolski, P. Yu, D. S. Sanchez, Y. Ishida, T. R. Chang, S. T. S. Zhang, S. Y. Xu, H. Zheng, G. Q. Chang, G. Bian, H. T. Jeng, T. Kondo, H. Lin, Z. Liu, S. Shin, and M. Z. Hasan, Nat. Commun. 8, 942 (2017).
- [13] E. Haubold, K. Koepernik, D. Efremov, S. Khim, A. Fedorov, Y. Kushnirenko, J. van den Brink, S. Wurmehl, B. Büchner, T. K. Kim, M. Hoesch, K. Sumida, K. Taguchi, T. Yoshikawa, A. Kimura, T. Okuda, and S. V. Borisenko, Phys. Rev. B 95, 241108(R) (2017).
- [14] X. Q. Zhou, Q. H. Liu, Q. S. Wu, T. Nummy, H. X. Li, J. Griffith, S. Parham, J. Waugh, E. Emmanouilidou, B. Shen, O. V. Yazyev, N. Ni, and D. Dessau, Phys. Rev. B 97, 241102(R) (2018).
- [15] J. W. Liu, H. Wang, C. Fang, L. Fu, and X. F. Qian, Nano Lett. 17, 467 (2017).

a QSH insulator. Meanwhile, a topological phase transition is observed by increasing the interlayer distance in bilayer TaIrTe₄.

Acknowledgments. This work was supported by the National Key R&D Program of China (Grants No. 2017YFA0302903 and No. 2018YFE0202700), the National Natural Science Foundation of China (Grants No. 11774422, No. 11774424, No. 11622437, and No. 11974422), the Strategic Priority Research Program [Chinese Academy of Sciences (CAS)] (Grant No. XDB30000000), the CAS Interdisciplinary Innovation Team, the Fundamental Research Funds for the Central Universities, and the Research Funds of Renmin University of China (Grants No. 16XNLQ01, No. 19XNLG13, and No. 19XNQ025). Computational resources have been provided by the Physical Laboratory of High Performance Computing at Renmin University of China.

- [16] X. Dong, M. Y. Wang, D. Y. Yan, X. L. Peng, J. Li, W. D. Xiao, Q. S. Wang, J. F. Han, J. Ma, Y. G. Shi, and Y. G. Yao, ACS Nano 13, 9571 (2019).
- [17] C. Liu, C. S. Lian, M. H. Liao, Y. Wang, Y. Zhong, C. Ding, W. Li, C. L. Song, K. He, X. C. Ma, W. H. Duan, D. Zhang, Y. Xu, L. L. Wang, and Q. K. Xue, Phys. Rev. Mater. 2, 094001 (2018).
- [18] J. S. Qiao, Y. H. Pan, F. Yang, C. Wang, Y. Chai, and W. Ji, Sci. Bull. 63, 159 (2018).
- [19] P. E. Blöchl, Phys. Rev. B 50, 17953 (1994).
- [20] G. Kresse and D. Joubert, Phys. Rev. B 59, 1758 (1999).
- [21] G. Kresse and J. Hafner, Phys. Rev. B 47, 558 (1993).
- [22] G. Kresse and J. Furthmüller, Comput. Mater. Sci. 6, 15 (1996).
- [23] G. Kresse and J. Furthmüller, Phys. Rev. B 54, 11169 (1996).
- [24] J. P. Perdew, K. Burke, and M. Ernzerhof, Phys. Rev. Lett. 77, 3865 (1996).
- [25] J. Klimeš, D. R. Bowler, and A. Michaelides, Phys. Rev. B 83, 195131 (2011).
- [26] A. Mar, S. Jobic, and J. A. Ibers, J. Am. Chem. Soc. 114, 8963 (1992).
- [27] Q. S. Wu, S. Zhang, H. F. Song, M. Troyer, and A. A. Soluyanov, Comput. Phys. Commun. 224, 405 (2018).
- [28] R. Zacharia, H. Ulbricht, and T. Hertel, Phys. Rev. B 69, 155406 (2004).
- [29] Y. N. Liu, Q. Q. Gu, Y. Peng, S. M. Qi, N. Zhang, Y. N. Zhang, X. M. Ma, R. Zhu, L. M. Tong, J. Feng, Z. Liu, and J. H. Chen, Adv. Mater. **30**, 1706402 (2018).
- [30] A. V. Krukau, O. A. Vydrov, A. F. Izmaylov, and G. E. Scuseria, J. Chem. Phys. **125**, 224106 (2006).
- [31] R. Yu, X. L. Qi, A. Bernevig, Z. Fang, and X. Dai, Phys. Rev. B 84, 075119 (2011).
- [32] J. W. Sun, A. Ruzsinszky, and J. P. Perdew, Phys. Rev. Lett. 115, 036402 (2015).
- [33] J. S. Qiao, X. Kong, Z. X. Hu, F. Yang, and W. Ji, Nat. Commun. 5, 4475 (2014).
- [34] Y. D. Zhao, J. S. Qiao, Z. H. Yu, P. Yu, K. Xu, S. P. Lau, W. Zhou, Z. Liu, X. R. Wang, W. Ji, and Y. Chai, Adv. Mater. 29, 1604230 (2016).

- [35] C. Wang, X. Y. Zhou, Y. H. Pan, J. S. Qiao, X. H. Kong, C. C. Kaun, and W. Ji, Phys Rev B 97, 245409 (2018).
- [36] S. Cai, E. Emmanouilidou, J. Guo, X. D. Li, Y. C. Li, K. Yang, A. Li, Q. Wu, N. Ni, and L. L. Sun, Phys. Rev. B 99, 020503(R) (2019).
- [37] D. F. Kang, Y. Z. Zhou, W. Yi, C. L. Yang, J. Guo, Y. G. Shi, S. Zhang, Z. Wang, C. Zhang, S. Jiang, A. G. Li, K. Yang, Q. Wu, G. M. Zhang, L. L. Sun, and Z. X. Zhao, Nat. Commun. 6, 7804 (2015).
- [38] X. C. Pan, X. L. Chen, H. M. Liu, Y. Q. Feng, Z. X. Wei, Y. H. Zhou, Z. H. Chi, L. Pi, F. Yen, F. Q. Song, X. G. Wan, Z. R. Yang, B. G. Wang, G. H. Wang, and Y. H. Zhang, Nat. Commun. 6, 7805 (2015).
- [39] E. Sajadi, T. Palomaki, Z. Y. Fei, W. J. Zhao, P. Bement, C. Olsen, S. Luescher, X. D. Xu, J. A. Folk, and D. H. Cobden, Science 362, 922 (2018).
- [40] X. X. Xi, Z. F. Wang, W. W. Zhao, J. H. Park, K. T. Law, H. Berger, L. Forró, J. Shan, and K. F. Mak, Nat. Phys. 12, 139 (2016).